



SDI Review Form 1.6

Journal Name:	Journal of Materials Science Research and Reviews
Manuscript Number:	Ms_JMSRR_46490
Title of the Manuscript:	Preparation and Physical Properties of CuxZn1-xS thin films Deposited by Metal Organic Chemical Vapour Deposition Technique.
Type of the Article	Original Research Article

General guideline for Peer Review process:

This journal's peer review policy states that **NO** manuscript should be rejected only on the basis of '**lack of Novelty**', provided the manuscript is scientifically robust and technically sound. To know the complete guideline for Peer Review process, reviewers are requested to visit this link:

(<http://www.sciencedomain.org/page.php?id=sdi-general-editorial-policy#Peer-Review-Guideline>)

PART 1: Review Comments

	Reviewer's comment	Author's comment (if agreed with reviewer, correct the manuscript and highlight that part in the manuscript. It is mandatory that authors should write his/her feedback here)
Compulsory REVISION comments	No comments	
Minor REVISION comments	In conclusions , add one or two commercial application	
Optional/General comments	Paper is good , ready to communicate	

PART 2:

	Reviewer's comment	Author's comment (if agreed with reviewer, correct the manuscript and highlight that part in the manuscript. It is mandatory that authors should write his/her feedback here)
Are there ethical issues in this manuscript?	<i>(If yes, Kindly please write down the ethical issues here in details)</i>	

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